RESIST REMOVER RR41

Description

Resist Remover RR41 is a stripping solution designed to remove photoresist from the surface of a substrate.

Properties

- Principal solvent: dimethyl sulfoxide
- Melting temperature (°C): 19
- Appearance: clear liquid
- Specific gravity at 23°C (g/cm3): 1.00 – 1.05
- Guaranteed shelf life at 23°C storage (years): 3

Processing

1. Pour the solution into a resist stripping tank.
2. Heat the solution to 100°C under an exhaust hood.
3. Place the resist coated substrate in the solution for 5 minutes.
4. Rinse the substrate with deionized water until the water resistivity reaches the prescribed limit.

Handling Precautions

Handle RR41 with care. Keep it away from heat, sparks and flames. Use adequate ventilation. It may be harmful if swallowed or touched. Avoid contact with liquid, vapor or spray mist. Wear chemical goggles, rubber gloves and protective clothing.